



GP/176
PATENT
MIC04 P-106

THE UNITED STATES PATENT AND TRADEMARK OFFICE

Group : 1763
Applicant : Imad Mahawili, PhD
Serial No. : 09/488,309
Filed : January 20, 2000
For : REACTOR WITH REMOTE PLASMA SYSTEM AND
METHOD OF PROCESSING A SEMICONDUCTOR SUBSTRATE

Attention: Official Draftsman
Assistant Commissioner for Patents
Washington, D.C. 20231

Dear Sir:

TRANSMITTAL OF FORMAL DRAWINGS

Applicant requests that the enclosed five (5) sheets of formal drawings be entered in the above identified application.

REMARKS

Enclosed please find five (5) sheets of formal drawings for filing in the present application. The enclosed drawings correspond to the informal drawings now on file.

Respectfully submitted,

IMAD MAHAWILI, PHD

By: Van Dyke, Gardner, Linn & Burkhart, LLP

September 12, 2000
Date

Catherine S. Collins
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Dear Sir:

CERTIFICATE OF MAIL

I certify that the attached return postcard, Transmittal of Formal Drawings,
and five (5) sheets of formal drawings are being deposited with the United States Postal
Service as first class mail in an envelope addressed to:

Attention: Official Draftsman
Assistant Commissioner for Patents
Washington, D.C. 20231

on September 12, 2000.


Lynette M. S. Clark
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(616) 975-5500

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Enclosures

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